Name of Examphatron — 2nd perpoderal test Roll No. (In fegures) — 1812968

Roll No. (In words) — Erghteen lakh, twelve thousand, none hundred staty erght

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Subject - MICROWAVE ENGINEERING

Paper with code — mircrowave Engineering,

Day and date of Examphation—Tuesday, 23-03-021

Total No. of pages excluding this page -8

Questron,	1	2	3	4	5	6
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Spanature of the student
mahalaxmin Kumari

$$Z_{L} = (100 + 1100) \Omega$$
 $Z_{0} = 50 \Omega$ 

The normalized load impedance, 
$$\overline{Z_L} = \frac{\overline{Z_L}}{\overline{Z_0}} = \frac{100 + 1100}{50}$$

$$= 2+12 \rightarrow 1et point A$$

NOW, draw constant SWR cricle through point A. we get wad y\_ = 0.24-90.25 at 0.2081 > tet point B admrtlance,

In admetance domain recordes —> 82 cricles and αι cricles → be cricles

for matching need to move towards generator q destance of such that yo has a real part equal to 1.

Thes condition es satisfied by two points c and D on smith chart, Corresponding to the intersections of the SWR errcle with the  $g_{L}=1$  circle.

NOW, for point c;

$$d(B,c) = (0.179 - 0.488) \lambda = -0.279 \lambda + 65 \lambda = 0.421 \lambda$$
to match:  $0.179 - 0.488 = 0.279 \lambda + 65 \lambda = 0.421 \lambda$ 

In order to match:  $y_{PN} = 1$ 

$$\therefore \left[ \forall s = -\$1.6 \right]$$

Name-mahalaxmpKumarf, RN-1812968, PN-2

so, we need a stub with admittance - 91.6. The normalized admittance of a short is -soo located at point E.

starting from E, we move towards generator until  $y = -91.6 \rightarrow$  point F (0.341).

Distance E-f gives stub length; l = 0.341 - 0.251 = 0.091

### for pornt D;

Yd = 1-II.6 pornt b located at 0.3224

 $d(B_1D) = (0.322 - 0.458) = -0.1361 + 0.51 = 0.3641$ 

in order to match; yrn=1

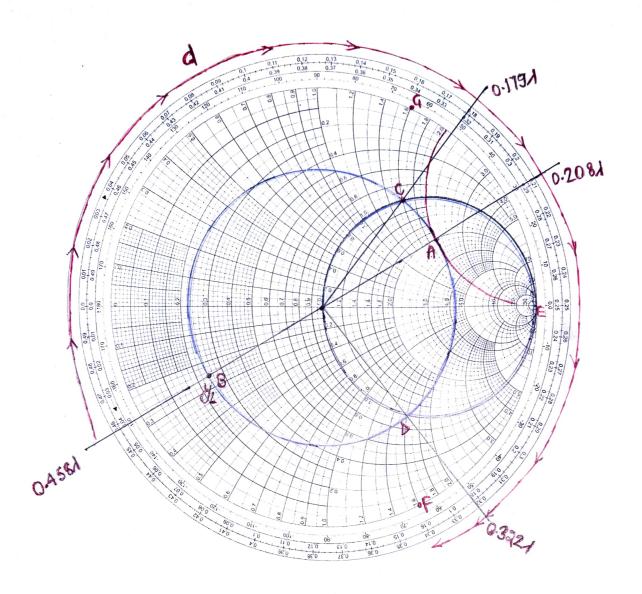
The needed normalized enput admittance of the stubes  $\forall s = $1.6$ , located at point G(0.161)

The normalized admethance of a short is  $-5\infty$  located at point E. starting from E, we move towards generator until,  $y = 51.6 \rightarrow$  point G (0.161)

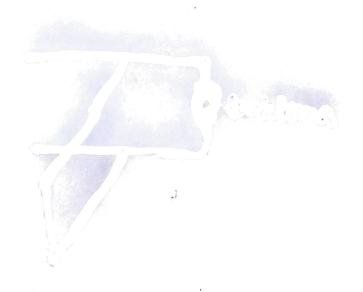
Destance E-4 grues stub length;

l= 0.251+0.161

·· l = 0.411



**Smith Chart** 



Name-mahalaxmekumare, R.N-1812968, P.N-4

# @ Ans: Baste operating mechanism of TRAPATT drode

TRAPATT drode -> derrued from the Trapped plasma Aualanche Triggered Transit mode deurce.

## Basecs of TRAPATT drode:

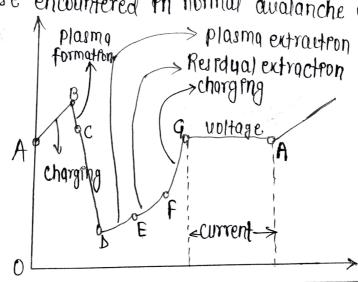
- frequency of operation 1 to 3KHz.
- -Norse fraure 60dB.
- It works with low power dessipation.
- -It works based on plasma Aualanche trigger.
- It has be to RF effectency between 0.8 to 60%.

   It is avallable with pt\_n-nt or nt-p-pt.
- -Trapath drode proupdes higher efficiency than impatt drode but et has hegher level norse tegure.

# prenceple of operation:

A high field avalanche zone propogates through the drode and fells the depletron layer with a dense plasma of electrons and holes that become trapped on the low freld region behind the zone.

The bourc eperation of the excelletor is a semiconductor p-n Junction drode reversed brased to current densities well in excess of those encountered on normal avalanche operation.



mahalaxung Kumarg

Name-mahalarume Kumarp, R.N-1812968 P.N-5

At point a electric freed is uniform throughout the sample but less than audlanche breakdown. Drode charge like a lenear capacitor.

when magnetude of electric field encreases above the breakdown woltage, then sufficient number of charge carrier is generated, the particle current (Ip) exceeds the external current (Ie), and the electric field is depressed throughout the depletion region, causing the woltage to decrease. B to c 9 dense plasma of electron and hele is generated.

At popul c to D some of the electrons and holes dreft out of the ends of the depletron layer the freld is further depressed and traps the remaining plasma.

A long time is required to remove the plasma as shown in graph from 1 to E.

At point E the plasma is removed, but residual charge of electron in one end of the depletion region and residual charge of holes en other ends.

At point fall the charges that was generated has been removed. The point f to 9 the drode charges like capacitor.

At point G drode current goes to zero for half a perfod and the weltage remains constant at us until the current comes back on and the cycle repeats.

The TRPATT mode can operate at Low frequencies since descharge time of plasmy can be considerably greater than the nominal transit time of the drode at high field.

manglanme Kumare

and perffue note gradual processe in dopping level, rather than abrupt change here. Junction

To cathode

heat spnk

Potentral

(trapped avalanche regron) frg: TRAPATT drode schematic

Consider an impatt diode mounted in a coaxial causty, so arranged that there is a short erroupt a half-wavelength away from the drode at the impatt operating frequency, when escrilations begin, most of the power well be reflected across the drode, and thus the RF freed across the drode well be many times the normal value for IMPATT operation. Thes well rapidly cause the total weltage across the drode to rese well above the breakdown threshold value used en impatt operation. As avalanche now takes place, a plasma of electrons and heles es generated, placing a large potential across the Junction, which opposes the applied de nottage. The total nettage es thereby reduced, and the current pulse is trapped behind et. when the pulse travels across the nt dreft region of the sems conductor chep, the neltage across of as thus much lower than PN IMPATT operation. They has two effects. The first is much slower dreft velocity, so that for a given thickness the operating frequency is several times lower than for corresponding IMPATT operation. The second point of great interest is that, when the current pulse does arrive at the cathode, the dode unleage is much lower than en an Impatt drode.

Hence, dreft through TRAPATT drode much slower than through a comparable Impatt drode. Ma balown & Kuman

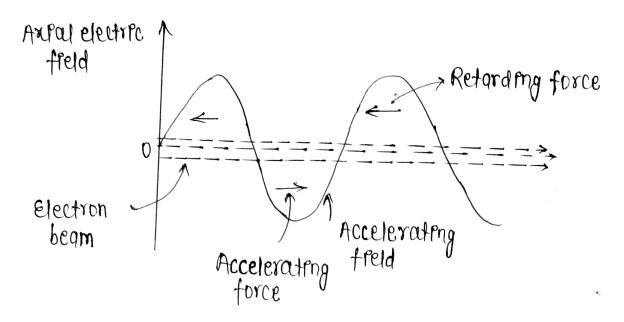
The travelling wave tube (TWT) is of the type in which an electron beam passes firstly through a hole in the anode and then through the centre of a cloverleaf slow wave structured before streking the collector.

Amplestation takes place en Two due to the Poteraction between the beam and the frelds assocrated with the structure, which has input and output waveguide. Windows at its ends and is at earth potential.

The RF signal, however, propagates at the speed of light and there must be a mechanism to slow down its speed to permit interaction between the beam and the signal. This slowdown is achieved by using a slow wave structure, which is usually a helix, and the slowed down RF signal is called slow wave. The aftenuator isolates the input and output sections to prevent ascellations. The velocity of the electron beam, travelling through the helix, induces adds energy to the RF waves on the helix, thus amplifying the signal.

#### Beam wave enteraction on Two deutce

The helfx TWT consests of a cathode, a collector, and a helfx that allows the RF to enteract weth the electron beam. When the electron enters the helfx tube, an enteraction takes place between moung areal electric field and moung electrons. The electrons entering the retarding field are electroted and those in accelerating field are accelerated. They begin forming a bunch centered around about those electrons that enters the helfx during the zero field.



and electric field.

### use et slow wave structure en TwT

Basecally the RF wave applied at the enput of TWT propagates with the speed of leght. Whele the propagating velocity of the electron beam enorde the tube es comparatively smaller than the velocity of RF wave.

if we try to somehow accelerate the velocity of the electron beam, then it can be accelerated only fraction of velocity of light. So it is better to reduce the velocity of the applied RF input in order to match the velocity of the electron beam. Therefore, a slow-wave structure is used that causes a reduction in the phase velocity of the RF wave inside the TWT.

Ania rama almatria

slow wave structures are special circuits that are used in microwave tubes to reduce wave velocity on a certain direction so that the electron beam and the signal wave can interact. In Two, since the beam can be accelerated only to velocities that are about a fraction of the velocity of light, slow wave structures are used.